

INFORMATION DISCLOSURE STATEMENT

Applicant : Yamazaki et al.
App. No : 10/566,425
Filed : January 30, 2006
For : POSITIVE RESIST COMPOSITION
AND METHOD OF FORMING
RESIST PATTERN
Examiner : John S. Y. Chu
Art Unit : 1975

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June 24, 2008

(DST)

Neil S. Bartfeld, Ph.D., Reg. No. 39,901

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 4 (four) references to be considered by the Examiner. Also enclosed are 3 (three) foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed before the receipt of a first Office Action on the merits, and presumably no fee is required. If a first Office Action on the merits was mailed before the mailing date of this Statement, the Commissioner is authorized to charge the fee set forth in 37 C.F.R. § 1.17(p) to Deposit Account No. 11-1410.

Respectfully submitted,
KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 6/24/08

By: 
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